| | Туре | L# | Hits | Search Text | DBs | Time Stamp |
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| 1 | BRS | L1 | 1027 | 703/13.ccls. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:45 |
| 2 | BRS | L3 | 9 | (granik-y).in. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:47 |
| 3 | BRS | L4 | 1 | (granik-y).in. and (distortion\$3)"." | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:47 |
| 4 | BRS | L5 | 0 | (granik-y).in. and (distortion\$3).clm. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:48 |
| 5 | BRS | L6 | 0 | (granik-y).in. and (mask).clm. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:48 |

| | Туре | L# | Hits | . Search Text | DBs | Time Stamp |
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| 6 | BRS | L7 | 0 | (granik-y).in. and (etch).clm. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:48 |
| 7 | BRS | L8 | 0 | (granik-y).in. and (optic\$3).clm. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:48 |
| 8 | BRS | L 9 | 5 | (schellenberg-f).in. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:49 |
| 9 | BRS | L11 | 0 | | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:49 |
| 10 | BRS | L14 | 71 | (mentor-graphics-corporation).as. and optical | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:50 |

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| 11 | BRS | L16 | 14 | (mentor-graphics-corporation).as. and optical and etch and mask | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:50 |
| 12 | BRS | L15 | 1 | (mentor-graphics-corporation).as. and optical and etch and mack | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:50 |
| 13 | BRS | L12 | 151 | | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:53 |
| 14 | BRS | L17 | 4172 | (mask same reticle same litho\$9) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:54 |
| 15 | BRS | L18 | 76 | (mask same reticle same litho\$9 same distortions) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:58 |

| | Туре | L# | Hits | Search Text | DBs | Time Stamp |
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| 16 | BRS | L19 | 16 | (mask same reticle same litho\$9 same distortions) and (read same data) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 13:59 |
| 17 | BRS | L20 | 2 | (mask same reticle same litho\$9 same distortions) and (read same data) and (simulation same etch) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:01 |
| 18 | BRS | L21 | 23 | (simul\$6 same etch same mask same reticle) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:02 |
| 19 | BRS | L22 | 25545 | | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:03 |
| 20 | BRS | L23 | 801 | ((optical adj process adj correction) or (OPC)) same (simula\$6) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:03 |

| | Туре | L# | Hits | Search Text | DBs | Time Stamp |
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| 21 | BRS | L24 | 195 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:04 |
| 22 | BRS | L25 | 33 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6 same distor\$6) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:05 |
| 23 | BRS | L26 | 32 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6 same distor\$6) and wafer | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:07 |
| 24 | BRS | L27 | 25 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6 same distor\$6) and wafer and (compen\$5) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:29 |
| 25 | BRS | L28 | 0 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6 same distor\$6) and wafer and (compen\$5) and (mask and recticle) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:07 |

| | Туре | L# | Hits | Search Text | DBs | Time Stamp |
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| 26 | BRS | L29 | 0 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6 same distor\$6) and wafer and (compen\$5) and (read and write) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:35 |
| 27 | BRS | L30 | 4 | "097 4 7190" | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:15 |
| 28 | BRS | L31 | 690 | ("09747190") and simulation and etch and | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:16 |
| 29 | BRS | L32 | 690 | | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:16 |
| 30 | BRS | L33 | 690 | | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 14:17 |
| 31 | BRS | L34 | 314 | "7017141".pn. and simulation and etch and distortions (OPC) and wafer and compensate | USPAT | 2007/02/02 14:17 |

| | Туре | L# | Hits | Search Text | DBs | Time Stamp |
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| 32 | BRS | L35 | 1 | "7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate | USPAT | 2007/02/02 14:18 |
| 33 | BRS | L36 | 1 | '7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read | USPAT | 2007/02/02 14:18 |
| 34 | BRS | L37 | 0 , | "7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and write | USPAT. | 2007/02/02 14:18 |
| 35 | BRS | L38 | 1 | "7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) | USPAT | 2007/02/02 14:19 |
| 36 | BRS | L39 | 1 | "7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle | USPAT | 2007/02/02 14:19 |
| 37 | BRS | L40 | 1 | "7017141" pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle and mask | USPAT | 2007/02/02 14:20 |
| 38 | BRS | L41 | 1 | "7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle and mask and (rule\$3) | USPAT | 2007/02/02 14:20 |
| 39 | BRS | L42 | 0 | "7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle and mask and (rule\$3) and table | USPAT | 2007/02/02 14:20 |
| 40 | BRS | L43 | 1 | "7017141".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle and mask and (rule\$3) | USPAT | 2007/02/02 14:23 |
| 41 | BRS | L44 | o | "6425113".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle and mask and (rule\$3) | USPAT | 2007/02/02 14:24 |
| 42 | BRS | L45 | 1 | "6415421".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle and mask and (rule\$3) | USPAT | 2007/02/02 14:47 |
| 43 | BRS | L46 | 1 | "6415421".pn. and simulation and etch and distortions and (OPC) and wafer and compensate and read and (writ\$6) and reticle and mask and (rule\$3) and lith\$9 | | 2007/02/02 15:29 |
| 44 | BRS | L47 | 0 | '6415421".pn. and bias | USPAT | 2007/02/02 15:29 |

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| 45 | BRS | L48 | 3 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6 same distor\$6) and wafer and (compen\$5) and bias | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:30 |
| 46 | BRS | L49 | 3 | ((optical adj process adj correction) or (OPC)) same (simula\$6) and (etch\$3 same simula\$6 same distor\$6) and bias | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:31 |
| 47 | BRS | L50 | 7295 | (etch same bias) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:38 |
| 48 | BRS | L51 | 3 | (etch same bias same reticle same distortion) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:39 |
| 49 | BRS | L52 | 38 | (etch same bias) and (reticle same distortion) | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:39 |

| | Туре | L# | Hits | Search Text | DBs | Time Stamp |
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| 50 | BRS | L53 | 36 | (etch same bias) and (reticle same distortion) and mask and reticle | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:40 |
| 51 | BRS | L54 | 14 | (etch same bias) and (reticle same distortion) and mask and reticle and simulation | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 15:44 |
| 52 | BRS | L55 | 1022 | 716/21.ccls. | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 16:21 |
| 53 | BRS | L56 | 180 | 716/21.ccls. and bias | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 16:22 |
| 54 | BRS | L57 | 72 | 716/21.ccls. and bias and etch | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO DERWEN T; IBM_TDB | 2007/02/02 16:23 |

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| 55 | BRS | L58 | 50 | 716/21.ccls. and bias and etch and simulation | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 16:23 |
| 56 | BRS | L59 | 54 | 716/21.ccls. and bias and etch and simul\$6 | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 16:23 |
| 57 | BRS | L60 | 14 | | US- PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWEN T; IBM_TDB | 2007/02/02 16:23 |

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